



RESPONSE UNDER 37. CFR 1.116  
EXPEDITED PROCEDURE  
EXAMINING GROUP 1755

AF

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

10/a we  
5/31/01  
B

In re application of

Tatsuhiko SHIBUYA et al.

Corres. and Mail  
BOX AF

Docket No.00774/98-129 TOK/US

Serial No. 09/302,471

Group Art Unit 1755

Filed April 30, 1999

Examiner D. Brunzman

SILICA-BASED COATING FILM ON  
SUBSTRATE AND COATING SOLUTION  
THEREFOR

RESPONSE TO FINAL REJECTION

Assistant Commissioner for Patents,  
Washington, D.C.

THE COMMISSIONER IS AUTHORIZED  
TO CHARGE AND DEPOSIT IN THE  
FEE FOR THIS PAPER TO DEPOSIT  
ACCOUNT NO. 23-0975.

Sir:

In response to the Final Rejection dated February 27, 2001, please amend the present application as follows:

IN THE CLAIMS:

Please cancel claims 1 to 6 and 16 without prejudice to the subject matter thereof.

RECEIVED  
MAY 30 2001  
TC 1700 MAIL ROOM